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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Robert J. SMALL et al.

Confirmation No: 5914

Application No.: 10/690,626

Art Unit: 1755

Filed: October 23 2003

Examiner:

For: **PARTICULATE OR PARTICLE-BOUND
CHELATING AGENTS**

Atty Docket No.: 060937-217-US

INFORMATION DISCLOSURE STATEMENT

U.S. Patent and Trademark Office
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Arlington, Virginia 22202

Sir:

In accordance with the duty of disclosure provisions of 37 C.F.R. §1.56, there is hereby provided certain information which the Examiner may consider material to the examination of the subject U.S. patent application. It is requested that the Examiner make this information of record if it is deemed material to the examination of the application.

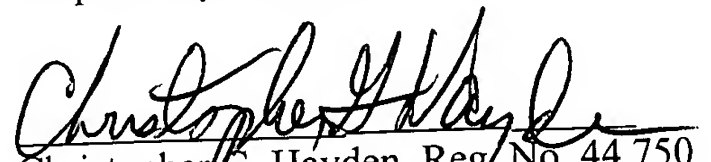
Enclosed with this Information Disclosure Statement is a list of all patents, publications, applications, or other information submitted for consideration by the Office. There are fifty-four (54) references listed in the above-referenced application; no U.S. references are submitted, however, the seven (7) foreign references, and one (1) article are submitted herewith. Remaining references can be provided upon request.

No fee is believed to be due for this submission, since this Information Disclosure Statement is being submitted before the first Office Action. Should any fees be required, however, please charge the required fees to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310.

Respectfully submitted,

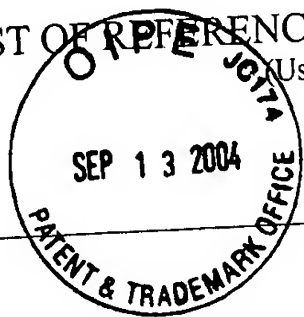
September 13, 2004

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LIST OF REFERENCES CITED BY APPLICANT

(Use several sheets if necessary)



ATTY DOCKET NO.

060937-0217

APPLICATION NO

10/690,626

APPLICANT

Robert J. SMALL et al.

FILING DATE

October 24, 2003

GROUP

1755

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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							YES	NO
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EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.